

L Number	Hits	Search Text	DB	Time stamp
-	206312	\$fluoride	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/10/23 09:26
-	811774	\$16chloride	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/10/23 12:56
-	13523	etch\$3 same (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) and (halogen\$4 halide \$fluoride \$bromide \$iodide chlorine fluorine bromine iodine SF6 "SF.sub.6" SiF4 "SiF.sub.4" Si2F6 "Si.sub.2 F.sub.6" SiF2 "SiF.sub.2" SiF3 "SiF.sub.3" XeF2 "XeF.sub.2" xenon adj (fluoride difluoride))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/10/23 13:15
-	7281	etch\$3 same (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) and \$16chloride	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/10/23 13:03
-	16416	(etch\$3 same (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) and (halogen\$4 halide \$fluoride \$bromide \$iodide chlorine fluorine bromine iodine SF6 "SF.sub.6" SiF4 "SiF.sub.4" Si2F6 "Si.sub.2 F.sub.6" SiF2 "SiF.sub.2" SiF3 "SiF.sub.3" XeF2 "XeF.sub.2" xenon adj (fluoride difluoride))) (etch\$3 same (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) and \$16chloride)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/10/23 13:03
-	8658	etch\$3 with (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) and ((etch\$3 same (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) and (halogen\$4 halide \$fluoride \$bromide \$iodide chlorine fluorine bromine iodine SF6 "SF.sub.6" SiF4 "SiF.sub.4" Si2F6 "Si.sub.2 F.sub.6" SiF2 "SiF.sub.2" SiF3 "SiF.sub.3" XeF2 "XeF.sub.2" xenon adj (fluoride difluoride))) (etch\$3 same (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) and \$16chloride))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/10/23 13:04
-	1351	etch\$3 near (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) and (etch\$3 with (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) and ((etch\$3 same (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) and (halogen\$4 halide \$fluoride \$bromide \$iodide chlorine fluorine bromine iodine SF6 "SF.sub.6" SiF4 "SiF.sub.4" Si2F6 "Si.sub.2 F.sub.6" SiF2 "SiF.sub.2" SiF3 "SiF.sub.3" XeF2 "XeF.sub.2" xenon adj (fluoride difluoride))) (etch\$3 same (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) and \$16chloride)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/10/23 13:05

-	823	etch\$3 adj (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) and (etch\$3 near (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) and (etch\$3 with (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) and ((etch\$3 same (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) and (halogen\$4 halide \$fluoride \$bromide \$iodide chlorine fluorine bromine iodine SF6 "SF.sub.6" SiF4 "SiF.sub.4" Si2F6 "Si.sub.2 F.sub.6" SiF2 "SiF.sub.2" SiF3 "SiF.sub.3" XeF2 "XeF.sub.2" xenon adj (fluoride difluoride))) (etch\$3 same (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) and \$16chloride))))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/10/23 13:12
-	359	etch\$3 adj (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) same (\$16chloride halogen\$4 halide \$fluoride \$bromide \$iodide chlorine fluorine bromine iodine SF6 "SF.sub.6" SiF4 "SiF.sub.4" Si2F6 "Si.sub.2 F.sub.6" SiF2 "SiF.sub.2" SiF3 "SiF.sub.3" XeF2 "XeF.sub.2" xenon adj (fluoride difluoride))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/10/23 13:08
-	235	etch\$3 adj (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) with (\$16chloride halogen\$4 halide \$fluoride \$bromide \$iodide chlorine fluorine bromine iodine SF6 "SF.sub.6" SiF4 "SiF.sub.4" Si2F6 "Si.sub.2 F.sub.6" SiF2 "SiF.sub.2" SiF3 "SiF.sub.3" XeF2 "XeF.sub.2" xenon adj (fluoride difluoride))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/10/23 13:13
-	75	(etch\$3 adj (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) with (\$16chloride halogen\$4 halide \$fluoride \$bromide \$iodide chlorine fluorine bromine iodine SF6 "SF.sub.6" SiF4 "SiF.sub.4" Si2F6 "Si.sub.2 F.sub.6" SiF2 "SiF.sub.2" SiF3 "SiF.sub.3" XeF2 "XeF.sub.2" xenon adj (fluoride difluoride))) and (Ir iridium)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/10/23 13:11
-	53	((etch\$3 adj (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) with (\$16chloride halogen\$4 halide \$fluoride \$bromide \$iodide chlorine fluorine bromine iodine SF6 "SF.sub.6" SiF4 "SiF.sub.4" Si2F6 "Si.sub.2 F.sub.6" SiF2 "SiF.sub.2" SiF3 "SiF.sub.3" XeF2 "XeF.sub.2" xenon adj (fluoride difluoride))) and (Ir iridium)) and iridium	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/10/23 13:11
-	150	(etch\$3 adj (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) with (\$16chloride halogen\$4 halide \$fluoride \$bromide \$iodide chlorine fluorine bromine iodine SF6 "SF.sub.6" SiF4 "SiF.sub.4" Si2F6 "Si.sub.2 F.sub.6" SiF2 "SiF.sub.2" SiF3 "SiF.sub.3" XeF2 "XeF.sub.2" xenon adj (fluoride difluoride))) and (Pt Pd Ir Rh platinum palladium iridium rhodium)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/10/23 13:14

-	48	(etch\$3 adj (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) with (\$16chloride halogen\$4 halide \$fluoride \$bromide \$iodide chlorine fluorine bromine iodine SF6 "SF.sub.6" SiF4 "SiF.sub.4" Si2F6 "Si.sub.2 F.sub.6" SiF2 "SiF.sub.2" SiF3 "SiF.sub.3" XeF2 "XeF.sub.2" xenon adj (fluoride difluoride))) and (SF6 "SF.sub.6" SiF4 "SiF.sub.4" Si2F6 "Si.sub.2 F.sub.6" SiF2 "SiF.sub.2" SiF3 "SiF.sub.3" XeF2 "XeF.sub.2" xenon adj (fluoride difluoride))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/10/23 13:21
-	424	((etch\$3 same (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) and (halogen\$4 halide \$fluoride \$bromide \$iodide chlorine fluorine bromine iodine SF6 "SF.sub.6" SiF4 "SiF.sub.4" Si2F6 "Si.sub.2 F.sub.6" SiF2 "SiF.sub.2" SiF3 "SiF.sub.3" XeF2 "XeF.sub.2" xenon adj (fluoride difluoride))) (etch\$3 same (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) and (\$16chloride)) and (SiF4 "SiF.sub.4"))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/10/23 13:18
-	230	(etch\$3 with (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) and ((etch\$3 same (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) and (halogen\$4 halide \$fluoride \$bromide \$iodide chlorine fluorine bromine iodine SF6 "SF.sub.6" SiF4 "SiF.sub.4" Si2F6 "Si.sub.2 F.sub.6" SiF2 "SiF.sub.2" SiF3 "SiF.sub.3" XeF2 "XeF.sub.2" xenon adj (fluoride difluoride))) (etch\$3 same (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) and (\$16chloride))) and (SiF4 "SiF.sub.4"))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/10/23 13:19
-	33	(etch\$3 near (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) and (etch\$3 with (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) and ((etch\$3 same (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) and (halogen\$4 halide \$fluoride \$bromide \$iodide chlorine fluorine bromine iodine SF6 "SF.sub.6" SiF4 "SiF.sub.4" Si2F6 "Si.sub.2 F.sub.6" SiF2 "SiF.sub.2" SiF3 "SiF.sub.3" XeF2 "XeF.sub.2" xenon adj (fluoride difluoride))) (etch\$3 same (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) and (\$16chloride)))) and (SiF4 "SiF.sub.4"))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/10/23 13:20

-	19	(etch\$3 adj (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) and (etch\$3 near (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) and (etch\$3 with (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) and ((etch\$3 same (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) and (halogen\$4 halide \$fluoride \$bromide \$iodide chlorine fluorine bromine iodine SF6 "SF.sub.6" SiF4 "SiF.sub.4" Si2F6 "Si.sub.2 F.sub.6" SiF2 "SiF.sub.2" SiF3 "SiF.sub.3" XeF2 "XeF.sub.2" xenon adj (fluoride difluoride))) (etch\$3 same (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) and \$16chloride)))) and (SiF4 "SiF.sub.4")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/10/23 13:20
-	9	(etch\$3 adj (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) same (\$16chloride halogen\$4 halide \$fluoride \$bromide \$iodide chlorine fluorine bromine iodine SF6 "SF.sub.6" SiF4 "SiF.sub.4" Si2F6 "Si.sub.2 F.sub.6" SiF2 "SiF.sub.2" SiF3 "SiF.sub.3" XeF2 "XeF.sub.2" xenon adj (fluoride difluoride))) and (SiF4 "SiF.sub.4")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/10/23 13:20
-	7	(etch\$3 adj (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) with (\$16chloride halogen\$4 halide \$fluoride \$bromide \$iodide chlorine fluorine bromine iodine SF6 "SF.sub.6" SiF4 "SiF.sub.4" Si2F6 "Si.sub.2 F.sub.6" SiF2 "SiF.sub.2" SiF3 "SiF.sub.3" XeF2 "XeF.sub.2" xenon adj (fluoride difluoride))) and (SiF4 "SiF.sub.4")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/10/23 13:20
-	33	((etch\$3 same (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) and (halogen\$4 halide \$fluoride \$bromide \$iodide chlorine fluorine bromine iodine SF6 "SF.sub.6" SiF4 "SiF.sub.4" Si2F6 "Si.sub.2 F.sub.6" SiF2 "SiF.sub.2" SiF3 "SiF.sub.3" XeF2 "XeF.sub.2" xenon adj (fluoride difluoride))) (etch\$3 same (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) and \$16chloride)) and (Si2F6 "Si.sub.2 F.sub.6")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/10/23 14:25
-	15	(etch\$3 with (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) and ((etch\$3 same (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) and (halogen\$4 halide \$fluoride \$bromide \$iodide chlorine fluorine bromine iodine SF6 "SF.sub.6" SiF4 "SiF.sub.4" Si2F6 "Si.sub.2 F.sub.6" SiF2 "SiF.sub.2" SiF3 "SiF.sub.3" XeF2 "XeF.sub.2" xenon adj (fluoride difluoride))) (etch\$3 same (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) and \$16chloride))) and (Si2F6 "Si.sub.2 F.sub.6")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/10/23 13:22

-	2	(etch\$3 near (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) and (etch\$3 with (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) and ((etch\$3 same (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) and (halogen\$4 halide \$fluoride \$bromide \$iodide chlorine fluorine bromine iodine SF6 "SF.sub.6" SiF4 "SiF.sub.4" Si2F6 "Si.sub.2 F.sub.6" SiF2 "SiF.sub.2" SiF3 "SiF.sub.3" XeF2 "XeF.sub.2" xenon adj (fluoride difluoride))) (etch\$3 same (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) and \$l6chloride)))) and (Si2F6 "Si.sub.2 F.sub.6")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/10/23 13:22
-	2	(etch\$3 adj (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) and (etch\$3 near (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) and (etch\$3 with (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) and ((etch\$3 same (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) and (halogen\$4 halide \$fluoride \$bromide \$iodide chlorine fluorine bromine iodine SF6 "SF.sub.6" SiF4 "SiF.sub.4" Si2F6 "Si.sub.2 F.sub.6" SiF2 "SiF.sub.2" SiF3 "SiF.sub.3" XeF2 "XeF.sub.2" xenon adj (fluoride difluoride))) (etch\$3 same (noble adj metal Pt Pd Ir Rh Ag Au Ru Os platinum palladium rhodium silver gold ruthenium osmium) and \$l6chloride)))) and (Si2F6 "Si.sub.2 F.sub.6")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/10/23 13:51
-	106	etch\$3 same (Pt Pd Ir Rh platinum palladium iridium rhodium) and (SiF4 "SiF.sub.4")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/01 11:59
-	222	etch\$3 and (Si2F6 "Si.sub.2 F.sub.6" silicon adj hexafluoride siliconhexafluoride)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/01 11:58
-	7	etch\$3 same (Pt Pd Ir Rh platinum palladium iridium rhodium) and (Si2F6 "Si.sub.2 F.sub.6" silicon adj hexafluoride siliconhexafluoride)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/01 11:59

L Number	Hits	Search Text	DB	Time stamp
-	106	etch\$3 same (Pt Pd Ir Rh platinum palladium iridium rhodium) and (SiF4 "SiF.sub.4")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/10/23 14:35
-	49	etch\$3 with (Pt Pd Ir Rh platinum palladium iridium rhodium) and (SiF4 "SiF.sub.4")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/10/23 14:35
-	10	etch\$3 near (Pt Pd Ir Rh platinum palladium iridium rhodium) and (SiF4 "SiF.sub.4")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/10/23 14:35
-	31	etch\$3 same (Pt Pd Ir Rh platinum palladium iridium rhodium) same (SiF4 "SiF.sub.4")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/10/23 14:35
-	5	etch\$3 with (Pt Pd Ir Rh platinum palladium iridium rhodium) with (SiF4 "SiF.sub.4")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/10/23 14:36
-	8	etch\$3 with (Pt Pd Ir Rh platinum palladium iridium rhodium) same (SiF4 "SiF.sub.4")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/10/23 14:53
-	2	etch\$3 same (Pt Pd Ir Rh platinum palladium iridium rhodium) same (Si2F6 "Si.sub.2 F.sub.6")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/29 13:16
-	5	etch\$3 same (Pt Pd Ir Rh platinum palladium iridium rhodium) and (Si2F6 "Si.sub.2 F.sub.6")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/10/23 15:04
-	3	(etch\$3 same (Pt Pd Ir Rh platinum palladium iridium rhodium) and (Si2F6 "Si.sub.2 F.sub.6")) not (etch\$3 same (Pt Pd Ir Rh platinum palladium iridium rhodium) same (Si2F6 "Si.sub.2 F.sub.6"))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/10/23 14:56
-	2	etch\$3 and (Pt Pd Ir Rh platinum palladium iridium rhodium) same (Si2F6 "Si.sub.2 F.sub.6")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/10/23 15:01
-	110	etch\$3 and (Pt Pd Ir Rh platinum palladium iridium rhodium) and (Si2F6 "Si.sub.2 F.sub.6")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/01 08:17
-	4	etch\$3 same (Pt Pd Ir Rh platinum palladium iridium rhodium) and etch\$3 same (Si2F6 "Si.sub.2 F.sub.6")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/10/23 15:06
-	6	etch\$3 same (Si2F6 "Si.sub.2 F.sub.6") and (Pt Pd Ir Rh platinum palladium iridium rhodium)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/10/23 15:07
-	2	(etch\$3 and (Pt Pd Ir Rh platinum palladium iridium rhodium) and (Si2F6 "Si.sub.2 F.sub.6")) and etch\$3 near (Pt Pd Ir Rh platinum palladium iridium rhodium)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/10/23 15:12

-	5	(etch\$3 and (Pt Pd Ir Rh platinum palladium iridium rhodium) and (Si2F6 "Si.sub.2 F.sub.6")) and etch\$3 same (Pt Pd Ir Rh platinum palladium iridium rhodium)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/10/23 15:12
-	2	(etch\$3 and (Pt Pd Ir Rh platinum palladium iridium rhodium) and (Si2F6 "Si.sub.2 F.sub.6")) and (Pt Pd Ir Rh platinum palladium iridium rhodium) same (Si2F6 "Si.sub.2 F.sub.6"))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/10/23 15:14
-	105	(etch\$3 and (Pt Pd Ir Rh platinum palladium iridium rhodium) and (Si2F6 "Si.sub.2 F.sub.6")) and (Pt Pd Rh platinum palladium iridium rhodium)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/10/23 15:14
-	4	((("6143191") or ("6018065") or ("6254792") or ("6340769")).PN.	USPAT	2003/11/01 07:23
-	2	etch\$3 and (Pt Pd Ir Rh platinum palladium iridium rhodium) same (Si2F6 "Si.sub.2 F.sub.6"))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/01 08:08
-	5	etch\$3 same (Pt Pd Ir Rh platinum palladium iridium rhodium) and(Si2F6 "Si.sub.2 F.sub.6"))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/01 08:08
-	6	(Pt Pd Ir Rh platinum palladium iridium rhodium) and (Si2F6 "Si.sub.2 F.sub.6")) same etch\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/01 08:09
-	103	etch\$3 and (Pt Pd Ir Rh platinum palladium iridium rhodium) and (Si2F6 "Si.sub.2 F.sub.6") not ((etch\$3 and (Pt Pd Ir Rh platinum palladium iridium rhodium) same (Si2F6 "Si.sub.2 F.sub.6")) (etch\$3 same (Pt Pd Ir Rh platinum palladium iridium rhodium) and(Si2F6 "Si.sub.2 F.sub.6")) ((Pt Pd Ir Rh platinum palladium iridium rhodium) and (Si2F6 "Si.sub.2 F.sub.6")) same etch\$3))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/01 10:06
-	4	("4659426" "5814238" "5911887" "6018065").PN.	USPAT	2003/11/01 10:05
-	3	(US-4659426-\$ or US-5814238-\$ or US-5911887-\$).did.	USPAT	2003/11/01 10:06
-	1	("5492855").PN.	USPAT	2003/11/01 10:07
-	4	((US-4659426-\$ or US-5814238-\$ or US-5911887-\$).did.) ("5492855").PN.)	USPAT	2003/11/01 10:07
-	133	etch\$3 same (Pt Pd Ir Rh Ag Cu Au Ru Os platinum palladium iridium rhodium silver copper gold ruthenium osmium) and (C2H6 "C.sub.2 H.sub.6"))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/29 14:42
-	36	(etch\$3 same (Pt Pd Ir Rh Ag Cu Au Ru Os platinum palladium iridium rhodium silver copper gold ruthenium osmium) and (C2H6 "C.sub.2 H.sub.6")) and ((O2 "O.sub.2" oxygen) same (C2H6 "C.sub.2 H.sub.6"))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/29 13:56
-	32	((etch\$3 same (Pt Pd Ir Rh Ag Cu Au Ru Os platinum palladium iridium rhodium silver copper gold ruthenium osmium) and (C2H6 "C.sub.2 H.sub.6")) and ((O2 "O.sub.2" oxygen) same (C2H6 "C.sub.2 H.sub.6"))) and plasma	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/29 16:05

-	97	(etch\$3 same (Pt Pd Ir Rh Ag Cu Au Ru Os platinum palladium iridium rhodium silver copper gold ruthenium osmium) and (C2H6 "C.sub.2 H.sub.6")) not ((etch\$3 same (Pt Pd Ir Rh Ag Cu Au Ru Os platinum palladium iridium rhodium silver copper gold ruthenium osmium) and (C2H6 "C.sub.2 H.sub.6")) and ((O2 "O.sub.2" oxygen) same (C2H6 "C.sub.2 H.sub.6"))))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/29 14:00
-	85	((etch\$3 same (Pt Pd Ir Rh Ag Cu Au Ru Os platinum palladium iridium rhodium silver copper gold ruthenium osmium) and (C2H6 "C.sub.2 H.sub.6")) not ((etch\$3 same (Pt Pd Ir Rh Ag Cu Au Ru Os platinum palladium iridium rhodium silver copper gold ruthenium osmium) and (C2H6 "C.sub.2 H.sub.6")) and ((O2 "O.sub.2" oxygen) same (C2H6 "C.sub.2 H.sub.6")))) and plasma	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/29 14:00
-	10	etch\$3 same (Ir iridium) and (C2H6 "C.sub.2 H.sub.6")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/29 16:37
-	519	etch\$3 same (Ir iridium) and (remote downstream microwave ecr)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/29 16:08
-	222	etch\$3 same (Ir iridium) and (remote downstream microwave ecr) with plasma	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/29 16:09
-	103	etch\$3 same (iridium) and (remote downstream microwave ecr) with plasma	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/29 16:09
-	67	etch\$3 with (iridium) and (remote downstream microwave ecr) with plasma	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/29 16:09
-	20	etch\$3 with (iridium) same (remote downstream microwave ecr) with plasma	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/29 16:09
-	66	etch\$3 same (Ir iridium) and (C2F6 "C.sub.2 F.sub.6")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/29 16:38
-	20	etch\$3 same iridium and (C2F6 "C.sub.2 F.sub.6")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/29 16:46
-	3	etch\$3 same iridium same (C2F6 "C.sub.2 F.sub.6")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/29 16:38
-	9	etch\$3 same (IR iridium) same (C2F6 "C.sub.2 F.sub.6")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/29 16:38

-	15	(etch\$3 same iridium and (C2F6 "C.sub.2 F.sub.6")) not (etch\$3 same (IR iridium) same (C2F6 "C.sub.2 F.sub.6"))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/29 16:46
-	7	etch\$3 same (Pt Pd Ir Rh platinum palladium iridium rhodium) and (Si2F6 "Si.sub.2 F.sub.6" silicon adj hexafluoride siliconhexafluoride)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/01 14:00
-	2061	SiF6 "SiF.sub.6" silicon adj hexafluoride siliconhexafluoride	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/01 13:15
-	2060	SiF6 "SiF.sub.6" silicon adj hexafluoride siliconhexafluoride adj (gas vapor)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/01 13:16
-	13	(SiF6 "SiF.sub.6" silicon adj hexafluoride siliconhexafluoride) adj (gas vapor)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/01 13:16
-	633	etch\$3 same (ir iridium) same (silicon quartz)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/01 15:04
-	250	etch\$3 same (iridium) same (silicon quartz)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/01 15:06
-	19	(etch\$3 same (iridium) same (silicon quartz)) and (silicon quartz) with react	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/01 15:07
-	1	(etch\$3 same (iridium) same (silicon quartz)) and (silicon quartz) adj react	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/01 15:07
-	9	(etch\$3 same (iridium) same (silicon quartz)) and (silicon quartz) near react	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/01 15:13
-	10	((etch\$3 same (iridium) same (silicon quartz)) and (silicon quartz) with react) not ((etch\$3 same (iridium) same (silicon quartz)) and (silicon quartz) near react)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/12/01 15:18